FORM PTO-1449 (Modified) U.S. Department of Commerce,

Patent and Trademark Office

Docket No.

Serial No. 09/918,395

INFORMATION DISCLOSURE STATEMENT BY APPLICANT

(Use several sheets if necessary)

Applicant

Ronald P. Reade et al.

Filing Date

Group

July 30, 2001

Unknown

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\*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with your communication to applicant.

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Date Considered

Examiner

FORM PTO-1449 (Modified)
U.S. Department of Commerce, Patent and Trademark Office

Docket No.

Serial No.

CIB-1632A

09/918,395

INFORMATION DISCLOSURE STATEMENT BY APPLICANT

(Use several sheets if necessary)

Applicant

Ronald P. Reade et al.

Filing Date

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## ELECTRONIC INFORMATION DISCLOSURE STATEMENT

Electronic Version v18 Stylesheet Version v18.0

> Title of Invention

ION TEXTURING METHODS AND ARTICLES

**Application Number:** 

09/918395

Confirmation Number:

9970

First Named Applicant: RONALD READE

Attorney Docket Number: IB-1632A

Art Unit:

1753

Examiner:

RODNEY GLENN MCDONALD

Search string:

( 6258472 or 6190752 or 6498549 or 6537689 or 5246741 or 4776925 or 5607781 or 5601654 or 6033471 or 5372089 or 20020017235 or

20020041973 or 20010006042 ).pn.

#### **US Patent Documents**

Note: Applicant is not required to submit a paper copy of cited US Patent Documents

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Note: Applicant is not required to submit a paper copy of cit d US Published Applications

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# Signature

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PTO/SB/08A (08-03)

Approved for use through 07/31/2006. OMB 0651-0031
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#### INFORMATION DISCLOSURE STATEMENT BY APPLICANT

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Application Number	09/918,395		
Filing Date	07/30/2001		U
First Named Inventor	Ronald P. Reade	O	111
Art Unit	1753		
Examiner Name	Rodney G. McDonald		_
Attorney Docket Number	IB-1632A	7	

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Examiner Initials*	Cite No.	Document Number	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear			
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